New features in the Raman spectrum of Silica: Key-points in the improvement on structure knowledge
M. Chligui, G. Guimbretiere, A. Canizares, G. Matzen, Y. Vaills, Patrick Simon

To cite this version:
M. Chligui, G. Guimbretiere, A. Canizares, G. Matzen, Y. Vaills, et al.. New features in the Raman spectrum of Silica: Key-points in the improvement on structure knowledge. 2010. hal-00520823

HAL Id: hal-00520823
https://hal.archives-ouvertes.fr/hal-00520823
Submitted on 24 Sep 2010

HAL is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

L’archive ouverte pluridisciplinaire HAL, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d’enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.
New features in the Raman spectrum of Silica:

Key-points in the improvement on structure knowledge

M. Chligui, G. Guimbretière, A. Canizarès, G. Matzen, Y. Vaills, P. Simon

CNRS/CEMHTI UPR3079, 1D Avenue de la Recherche Scientifique, 45071 Orléans, France, and
Université d’Orléans, 45067 Orléans Cedex 2, France

This paper reports the evidence of new signatures in the low-frequency Raman spectrum of silica, obtained by very high signal-to-noise experiments. Two new Raman lines are observed at 295 and 380 cm⁻¹, and the presence of a third one at 245 cm⁻¹ is needed to account for the experimental spectra. The origin of these supplementary lines is discussed in terms of n-membered rings of [SiO₄/2] tetrahedral entities inside the glassy network.

Amorphous silica (SiO₂) is one beyond the most-well known materials, with interests going from a model compound in glass physics up to numerous industrial applications for optics and electronics. A huge number of papers devoted to it stands in the literature, in such a point that its structure and dynamics look well-known and are then used as reference for the study of more complex systems. Raman scattering investigations for instance are numerous and it is then difficult today to identify the first report on silica. The Raman spectrum of silica is today rather well understood since the works by Galeener and Lucovsky thirty years ago 1,2 and confirmed by subsequent ab-initio calculations 3. The low-wavenumbers region of the silica Raman spectrum in the VV configuration polarization is usually decomposed as made of the boson peak at low wavenumbers (pointing around 50 cm⁻¹), a broad and asymmetric band at 450 cm⁻¹ assigned to δₚₑₑ_delta (SiOSi) bending vibrations (frequently referred as R-band), plus the D₁ and D₂ narrow peaks closed to 495 and 600 cm⁻¹. One widely accepted view of the structure of silica is a disordered more or less open network of corner-linked interconnected [SiO₄/2] tetrahedral entities. Such view intrinsically considers the existence of [SiO₄/2] membered rings (hereafter denoted MR), and as an evidence, the so-called D₁ and D₂ peaks are now unambiguously assigned to respectively four-tetrahedral (4-MR) and three-tetrahedra membered rings (3-MR). The specific dynamics of these MR was recently observed 4 by picosecond spectroscopy, that confirms the strong decoupling of these vibrations from the whole silica network. Nevertheless these assignments remain partially discussed, 5 with possible mixed influence of 3-MR and 4-MR in the D₁ band 6 and the absence of consensus in the estimation of rings population 7, 6, 8-9. Raman spectroscopy offers then a simple way to probe the statistics for 3 and 4-MR, and the greatest part of the literature devoted to rings statistics has focused on these small rings. However, the population of 3- and 4-MR is not dominant in silica compared to the whole MR distribution that can be obtained by molecular dynamics 7. Unfortunately, larger MR are rather hardly experimentally accessible, and very few knowledge is available on them apart from numerical approaches. In the literature one can found also some descriptions of the (SiOsi) bridges dynamic by force constant models 10, 11. These rather simple models link vibrational spectroscopic data with the average angle θ and effective forces constant of (SiOsi). From considerations of these models, the Raman signatures of 5-MR and 6-MR larger rings are expected to be at lower wavenumbers than for small rings, i.e., in the R-band region. Besides, independently of any specific ring patterns consideration, three different spectral features were suggested 12 to compose part of the isotropic R-band (symmetric stretching involving (SiOsi) bridges, δ_scis scissoring of [SiO₄/2], and Δ_scis scissoring of the [SiO₄/2]-[Si₄/4] extended tetrahedron). Therefore, it is not surprising that the R-band is sometimes described as the superposition of several individual symmetric bands (see for instance 13), but the proposed decompositions remain a little bit ambiguous as different band combinations can reproduce the broad experimental asymmetric shape, due to lack of any pointed inflexion point on the rising edge between 200 and 400 cm⁻¹.
This short paper reports very high signal-to-noise Raman spectra of silica that highlights new structuring in the broad asymmetric 450 cm⁻¹ R-band. These new features closed to 295 and 380 cm⁻¹ are observed here for the first time in the nonetheless well know spectrum of silica. They arise owing to increase of the signal-to-noise ratio and have to be considered after a rigorous and exhaustive study, in order to exclude any instrumental origin. So, in the following, we present first the experimental condition leading to the new spectral features observation. Next, we introduce and illustrate in a short discussion, the relevant consequence of such observations in the study of vitreous silicates structure by mean of Raman spectroscopy.

Experiments were done on two spectrometers: a Renishaw Invia Reflex with a Leica DM 2500 microscope (simple spectrometer configuration), and a Jobin-Yvon T64000 (triple subtractive configuration), in macro configuration. Both systems are multichannel ones with CCD detectors. Different excitation laser wavelengths were used: 457, 514 (Ar⁺ lines) and 633 nm (He-Ne line). Measurements with the Leica microscope were done with two objectives in order to check the effect of numerical aperture and the subsequent changes in light polarization. The specificities of the experiments reported here are the very long acquisition times (up to 20 hours), in order to substantially increase the signal-to-noise ratio. As in this case the saturation limit of the CCD detector can be attained, measurements were performed in accumulation mode (several subsequent spectra of lower time, to keep beyond the saturation limit, which are added at the end of experiment). Silica samples were of Corning 7980 type. A test was done on a 7980 sample, thermally treated to change the fictive temperature (Corning 7980 Tᵢ is 1040°C).

![Experimental VV Spectrum](a)

**FIG.1.** (a) Raman spectrum of silica (VV polarization configuration, 514.5 laser line, 90° configuration) with 17h of accumulation time. Arrows denote the position of the bumps visible on the rising edge of R-band. Dashed frame is the spectrum region derived in (b). (b) Derivative of the dash-enclosed part of the Raman spectrum of SiO₂, allowing accurate determination of the position of the bumps (indicated by arrows).

Figure 1 (a) displays the 25-650 cm⁻¹ frequency range of the VV polarized Raman spectrum of SiO₂, obtained on the Jobin-Yvon spectrometer, with the Ar⁺ 514.5 nm laser line, in macro- right angle configuration. This spectrum was acquired with a very long acquisition time (17h) in order to improve the signal-to-noise ratio. One can see, added to the well-known boson peak, R-band, D₁ and D₂ bands, two supplementary bumps, near 300 and 400 cm⁻¹. These bumps are rather broad and then they cannot give any detectable inflexion point on the rising edge of R-band if measurement is done with smaller acquisition times. As these bumps remain very small, possibility of any artifact in the experiment have been checked exhaustively: a first test to perform when recording such small and broad features is to check if there is no effect on non-uniform lightening on the CCD detector, by shifting the spectrograph of a small value: a non-uniform lightening stays at the same pixels whereas a real spectral feature shifts of pixels, to stay at the same wavenumbers. It was checked here that the two bumps are constant in wavenumbers. Other checks were done, to unambiguously establish that these bumps are intrinsic to the Raman response of silica. (i) Measurements were also done on the Renishaw Invia spectrometer (backscattering geometry and micro-Raman configuration) (ii) two other laser excitation lines were tried, i.e., 457 nm and 633 nm. (iv) Measurements with the Leica microscope
(Invia spectrometer) were done with two objectives (x20 and x50) in order to check the effect of numerical aperture and the possible subsequent changes in light polarization (v) changes of size of sample (from thickness of 1cm to 1mm), to check any interference or reflection effect between opposite faces. All these check measurements (all done with very long acquisition times) have confirmed the spectrum of figure 1(a) with its bumps. To determine more precisely the bump positions, it is useful to see the derivative of the spectrum (Figure 1(b)), much more sensitive to small features. The derivation was performed by the algorithm comprised in Microcal OriginPro8.1 software, with a Savitzky-Golay smoothing. The maximum of a peak in the original curve corresponds in the derivative curve to a zero value, or crossing through the baseline in the case of a peak superimposed to a broader and more intense feature. The bumps positions can then be determined rather precisely from figure 1(b):

\[ D_3 \approx 295 \text{ cm}^{-1}, \quad D_4 \approx 380 \text{ cm}^{-1} \]

Hereafter they will be called respectively D3 and D4 bands by analogy with the D1 and D2 bands.

Now that the presence of both \( D_3 \approx 295 \) and \( D_4 \approx 380 \text{ cm}^{-1} \) bands are established and even if to our knowledge, they were never reported explicitly before, one can remark that in some papers, the reported spectra have presumably exhibited them (13-14 for instance, among the most recent ones). Nevertheless, we underline that these features are very smooth compared to the underlying band and it was absolutely necessary to take specific acquisition times and to check for any possible artifact due to the experimental setup, as done in the present study. Above we have introduced that existence of numerous contributions to the Raman activity are expected in the R-band frequency region. Consequently, the possibility to fix the frequency of two of them has got considerable interest in the discussion of silicates structure.

In Figure 2, we present a new classic deconvolution of the spectrum. Generally, deconvolution results are dependent of the chosen band shapes and we have performed several tries. Figure 2 pictures one of these tries, where we have used a log normal shape for the boson peak, Lorentzian shapes for the D1 and D2 bands and Gaussian shapes for others. As one can see, additionally of the \( D_2 \approx 605 \text{ cm}^{-1}, \quad D_1 \approx 495 \text{ cm}^{-1}, \), the \( \approx 465 \text{ cm}^{-1} \) band (maximum of the R-band), the \( D_4 \approx 380 \text{ cm}^{-1} \) new feature, the \( D_3 \approx 295 \text{ cm}^{-1} \) new feature and the boson peak, a band closed to 245 cm\(^{-1}\) is necessary in order to fit the full Raman activity in this wavenumbers region. In fact, this latter additional contribution is a common result of all the deconvolutions that we have performed (not shown here).

First, we note that these frequencies do not coincide with those of any of the natural SiO\(_2\) crystalline polytypes (quartz, cristobalite, tridymite, stishovite, coesite) 15. Second, frequency of the \( \delta_{\text{bend}} \) (SiOSi) bending dynamic was successfully connected to the value of (SiOSi) angle (\( \theta \)) through simple effective force constant models10, 11. Therefore, consideration of the \( D_1 \) and \( D_2 \) bands through these models assign them as \( \delta_{\text{bend}} \) dynamic of (SiOSi) bridges with different \( \theta \). In fact, in the specific case of 3-MR and 4-MR, the (SiOSi) bridges forming the rings are vibrating in phase leading to a “breathing” dynamic of the rings poorly coupled with their environment. The 3- and 4-MR rings appear then obviously in the Raman spectrum despite their very small amount obtained from different calculations 7, 16: around one ring of each specie for more than 500 SiO\(_4\) tetrahedra according to Umari et al7. Then, if we consider, in one hand the (SiOSi) bridges in larger \( (n \geq 5) \) SiO\(_4\) membered rings (hereafter denoted 5+MR) and, in other hand the widely observed and calculated \( \theta \) distribution17-18, one can assign part of the R-band to \( \delta_{\text{bend}} \)
dynamic of (SiOSi) bridges in 5+MR. Thus, the spectral signatures of larger rings are expected to be certainly broader than D1 and D2, and lying at lower wavenumbers than these lines. In fact, in many of the amorphous SiO2 calculated densities of states available in the literature (see for instance16, 19, 7), one can see peaks or clear shoulders lying in the wavenumbers range of those evidenced in the present paper. Obviously, calculated features of large structures such as 5+MR will exhibit lower linewidths than experimental ones, at least as the limited number of atoms in numerical approaches hardens a good description of coupling between different oscillators. Besides, we assume that the rest of the Raman activity comes from the scissoring modes introduced in ref 12. In order to illustrate the spectral consequence of the 0 distribution, in the following, we consider the (SiOSi) angle distribution calculated by Yuan et al. 17. This calculation is consistent with NMR characterization of silica18 and gives (SiOSi) angle distribution centered to 147° with a full width at half maximum 23-30°. From the 0 distribution, the induced frequency distribution in the Raman signature of (SiOSi) δbend can be estimated by used of the Effective Force Constant model of Lucovsky19, with the limited frequency of the highest VV Raman doublet as frequency of the (SiOSi) asymmetric stretching that is also active in IR12. The distribution in frequency obtained is pictured by black crosses in Figure 2. In this calculation, the (SiOSi) δbend frequency for 0 = 147° is assumed to be at the 435 cm⁻¹ maximum. These assumption give an angle of ≈ 128° at the 3-MR frequency, consistent with others recent demonstrations20. One can see that above estimated δbend frequency distribution merges on both D3 ≈ 380 and ≈ 465 cm⁻¹ bands. Then, one of the most plausible structural elements that can be connected with them are effectively the 5+MR. In fact, one knows from molecular dynamics that the ring statistics in silica is dominated by such rings (between 5 and 10), whereas 3-MR and 4-MR, marginal in the statistics in silica is dominated by such rings (between 5 and 10), whereas 3-MR and 4-MR, marginal in the statistics20. One can see that above estimated δbend frequency distribution merges on both D3 ≈ 380 and ≈ 465 cm⁻¹ bands. Then, one of the most plausible structural elements that can be connected with them are effectively the 5+MR. In fact, one knows from molecular dynamics that the ring statistics in silica is dominated by such rings (between 5 and 10), whereas 3-MR and 4-MR, marginal in the statistics, appear obviously in the Raman spectrum due to their and more –MR). In an other hand, the “breathing” nature of the small rings dynamic at the origin of sharp well-defined D1 and D2 bands is difficult to be taken account in the case of larger rings that are undoubtfully more distorted and coupled with their environment. We postulate that reality of the Raman signature of δbend dynamic of (SiOSi) bridges should be between these two extreme cases: broad R-band due to the distribution in θ, and discrimination of the D3 ≈ 380 cm⁻¹ and ≈ 465 cm⁻¹ wave-numbers bands due to the presence of rings patterns. Therefore, this view allows an assignment of the two D3 ≈ 380 cm⁻¹ and ≈ 465 cm⁻¹ bands to (SiOSi) δbend in 5+MR. Besides, the lowest wavenumbers bands (≈ 245 cm⁻¹ 3-6 and D3 ≈ 295 cm⁻¹) can thus be assigned to δbend and Δo-o.

Above we have discussed a “classical deconvolution”. A rigorous discussion of the bands assignment containing band-shapes consideration needs to take also account of the Raman coupling parameter21 that was assumed to be mode and frequency dependent22. Such fine and complex discussion will be published elsewhere, being beyond the scope of this short paper where we essentially want to highlight the presence beyond doubt of two distinguishable new Raman spectral features in the R-band of silica: D3 ≈ 295 cm⁻¹ and D4 ≈ 380 cm⁻¹.

-------------------